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# Synthesis of complex oxides by ALCVD

Ola Nilsen

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# CVD

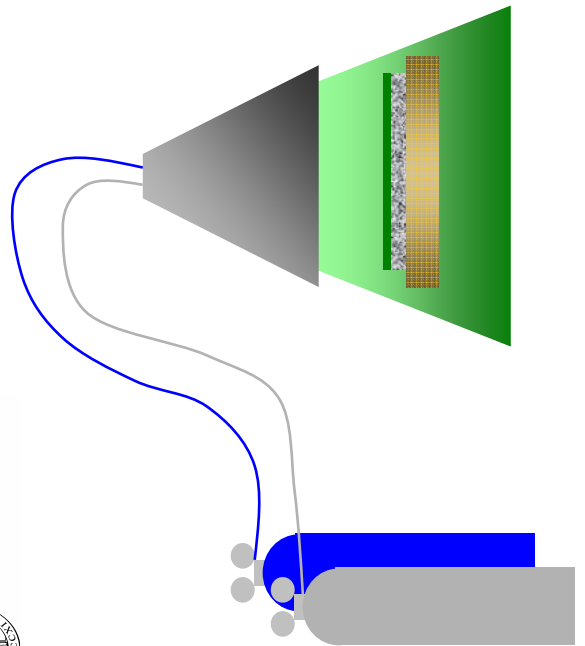
## Chemical Vapour Deposition

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# CVD (Chemical Vapour Deposition)

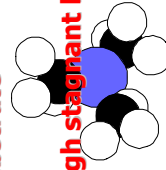


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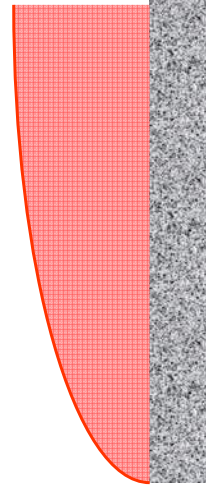


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Transport to substrate



Diffusion through stagnant layer



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CVD kinetics

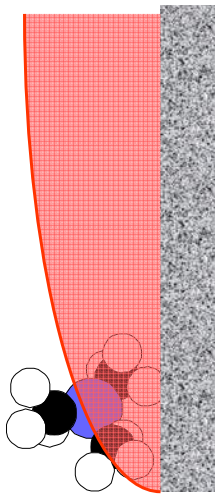
Transport to substrate

Transport from substrate

Diffusion through stagnant layer

Diffusion through stagnant layer

Reaction on the surface



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# ALCVD

## Atomic Layer Chemical Vapour Deposition

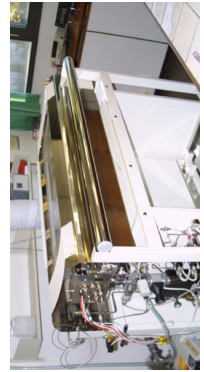
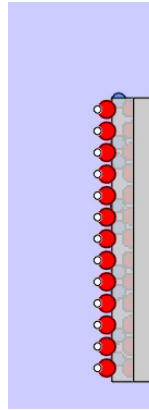
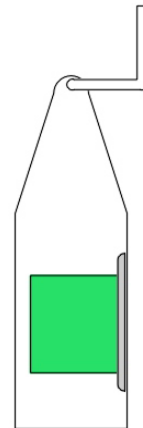
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# ALCVD principle

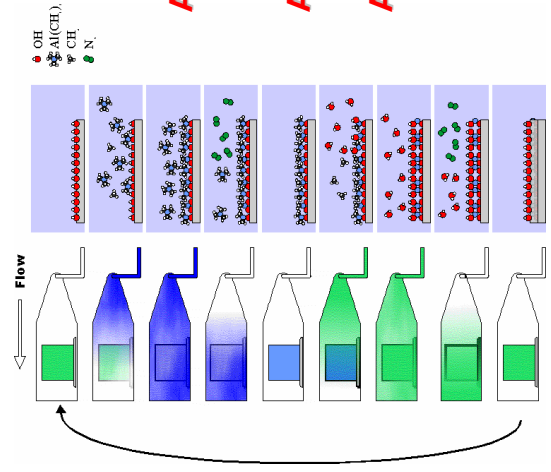
Flow



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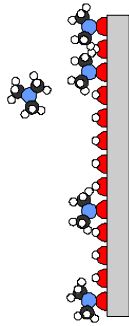
ALCVD Atomic Layer Chemical Vapour Deposition  
ALD Atomic Layer Deposition  
ALE Atomic Layer Epitaxy

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Growthkinetics



Growthrate

Sublimation

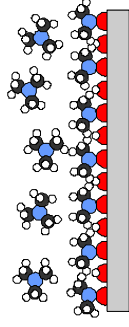
Temperature

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Growthkinetics



Growthrate

Sublimation

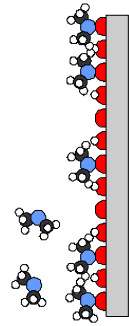
Temperature

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Growthkinetics



Growthrate

Sublimation

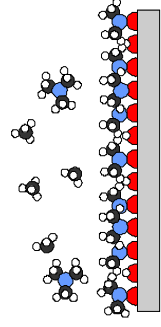
Temperature

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Growthkinetics



Growthrate

Sublimation

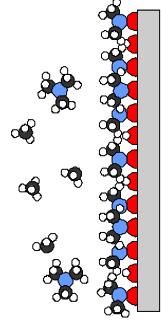
Temperature

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Growthkinetics



Growthrate

Sublimation

Temperature

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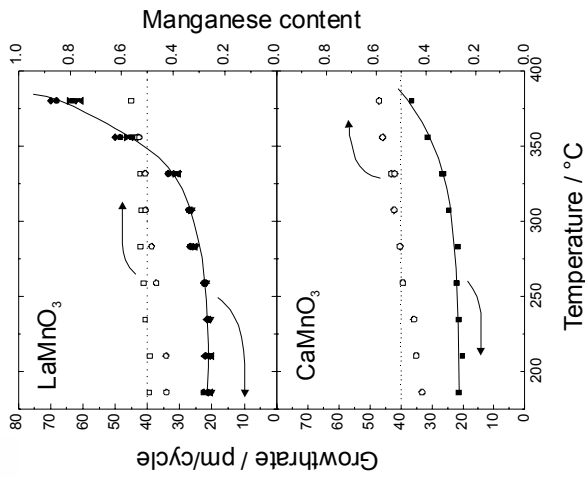
Decomposition

Desorbtion



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## ALCVD window

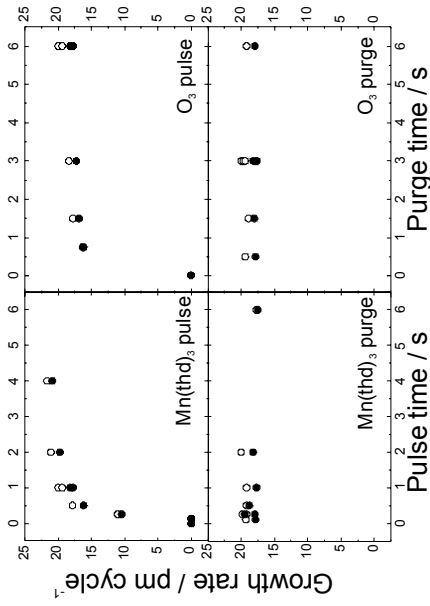


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## Pulse parameters

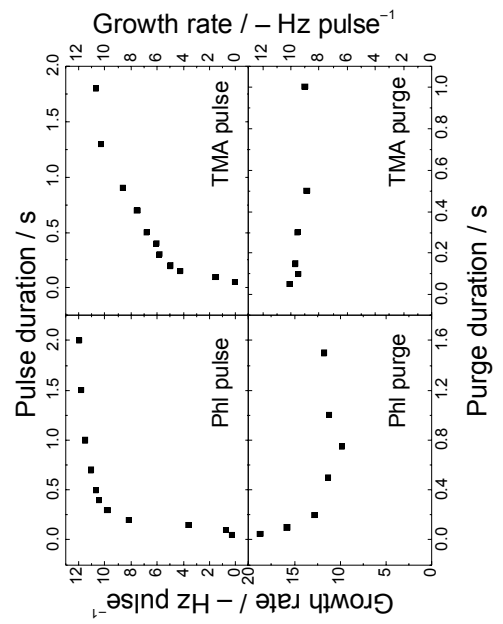


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## Pulsing parameters

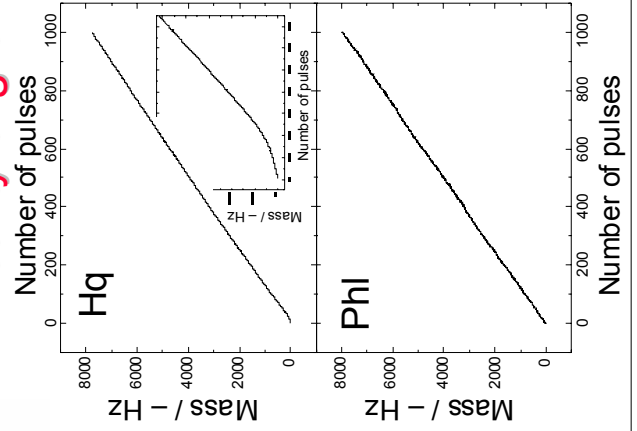


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## Linearity of growth

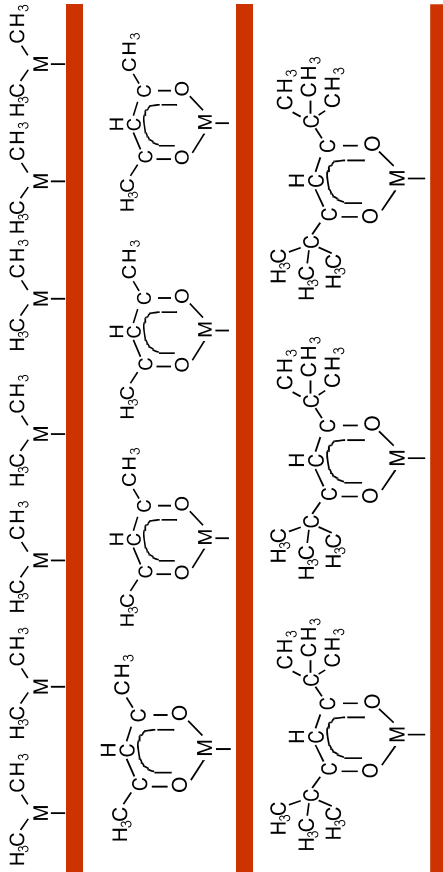


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## Surface coverage



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## Precursor requirements

### ALCVD

- Highly reactive
- Gaseous, liquid or solid
- Non reactive byproducts
- Thermally stable under reaction conditions

- Non toxic
- Easy to handle
- Inexpensive

-Low reactor temperature

### CVD

- Limited reactivity
- Gaseous or liquid
- Non reactive byproducts
- Decompose cleanly under reaction conditions

- Non toxic
- Easy to handle
- Inexpensive

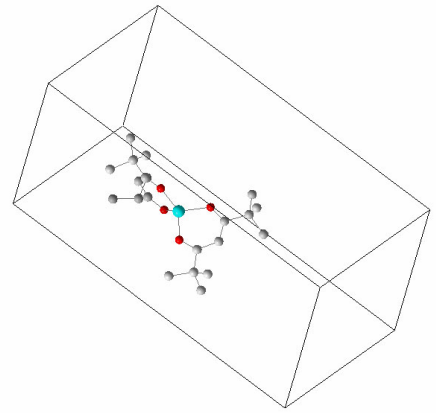
-High reactor temperature

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## Co(thd)<sub>2</sub>

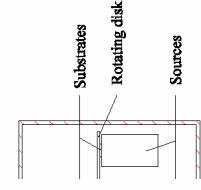
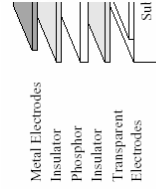


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## Reason for invention



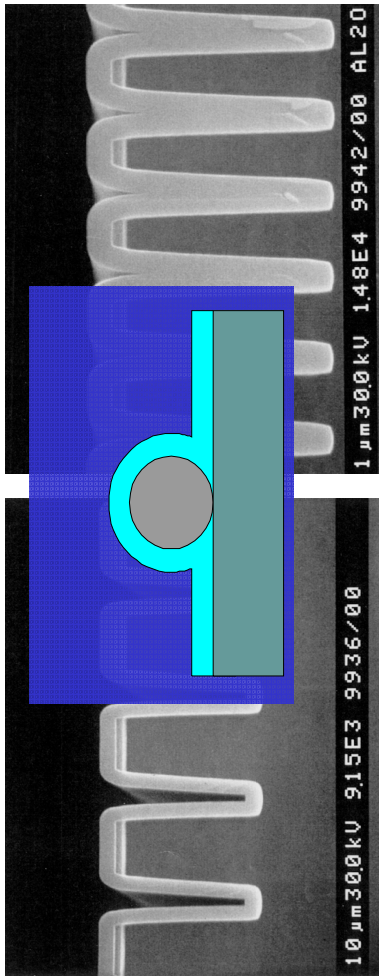
P

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# Uniform dense films

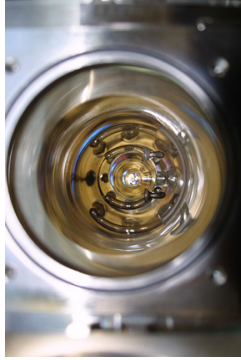


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# Reaction chamber

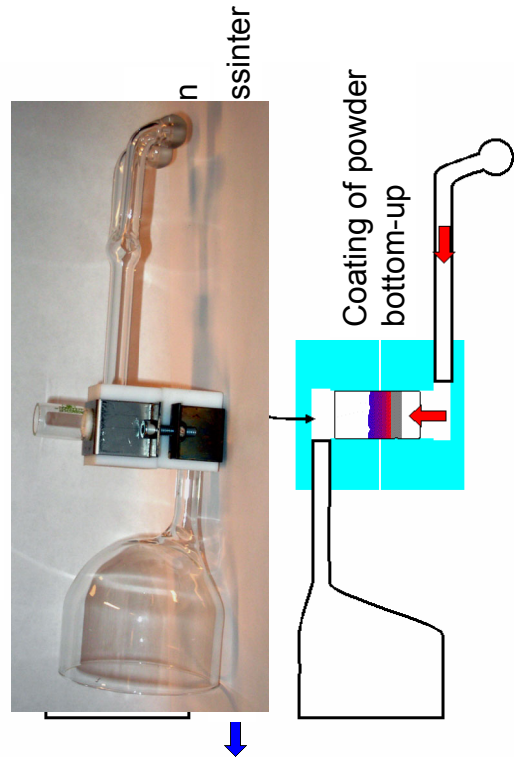


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# Powder cell

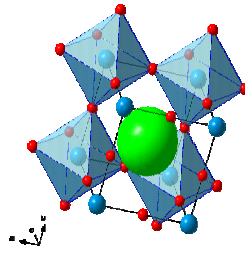


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# Perovskites



Currently grown by ALCVD:

### Compound

- BaTiO<sub>3</sub>
- Bi-Ti-O
- CaMnO<sub>3</sub>
- La<sub>1-x</sub>Ca<sub>x</sub>MnO<sub>3</sub>
- La<sub>1-x</sub>Sr<sub>x</sub>FeO<sub>3</sub>
- LaFeO<sub>3</sub>
- LaAlO<sub>3</sub>
- LaCoO<sub>3</sub>
- LaGaO<sub>3</sub>
- LaMnO<sub>3</sub>
- LaNiO<sub>3</sub>
- SrTiO<sub>3</sub>

### Reference

M. Vehkamäki et al., Electrochem. Solid-State Lett. 2(1999) 504.  
 M. Schuisky et al., Chem. Vap. Deposition, 6 (2000) 139.  
 O. Nilsen et al.  
 O. Nilsen et al.  
 M. Lie et al.  
 M. Lie et al.  
 M. Nieminen et al. J. Mater. Chem. 11 (2001) 2340.  
 H. Seim et al. Appl. Surf. Sci. 112 (1997) 243.  
 M. Nieminen et al. J. Mater. Chem. 11 (2001) 3148.  
 O. Nilsen et al.  
 H. Seim et al. J. Mater. Chem. 7 (1997) 449.  
 M. Vehkamäki et al., Electrochem. Solid-State Lett. 2(1999) 504.  
 A. Kosola et al., Appl. Surf. Sci. 211 (2003) 102.  
 M. Vehkamäki, et al. Chem. Vap. Deposition 7 (2001) 75.

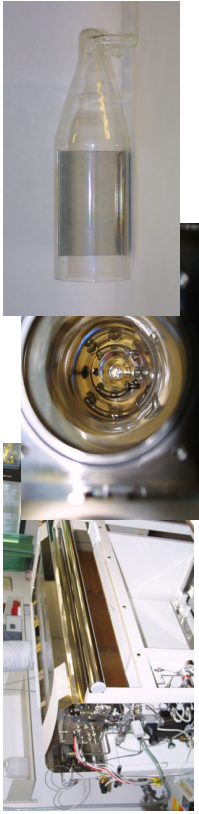
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## The growth of oxides

F-120 Sat reactor from ASM Microchemistry



Metal precursors:

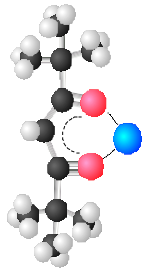
Ca(thd)<sub>2</sub> (Ca<sub>2</sub>(thd)<sub>6</sub>)

La(thd)<sub>3</sub>

Mn(thd)<sub>3</sub>

(Hthd = 2,2,6,6-tetramethylheptan-3,5-dione)

Oxygen source: O<sub>3</sub>

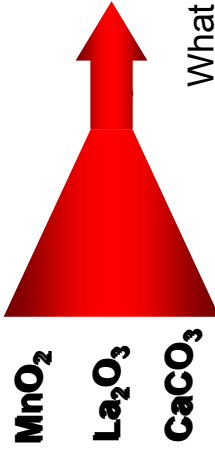


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## Growth of La<sub>1-x</sub>Ca<sub>x</sub>MnO<sub>3</sub>



What about:

Stoichiometry?

Carbonate?

ALD-window?

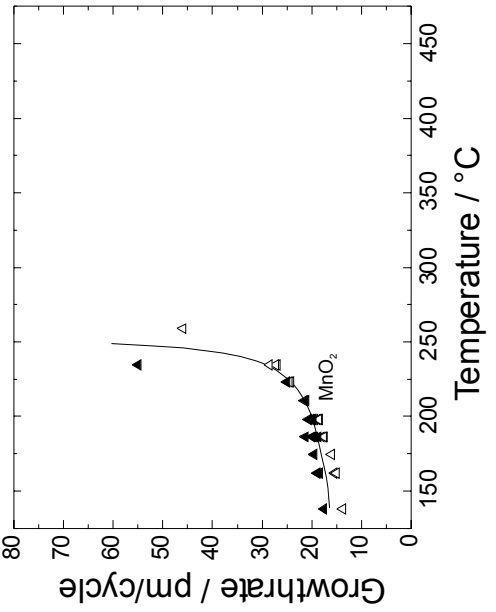
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## ALD-window

MnO<sub>2</sub>  
△ Soda-lime glass  
▲ Si(100)



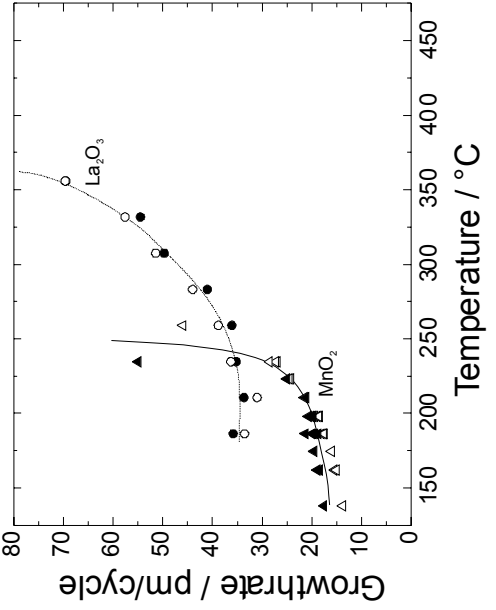
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## ALD-window

La<sub>2</sub>O<sub>3</sub>, MnO<sub>2</sub>  
○ Soda-lime glass  
● Si(100)



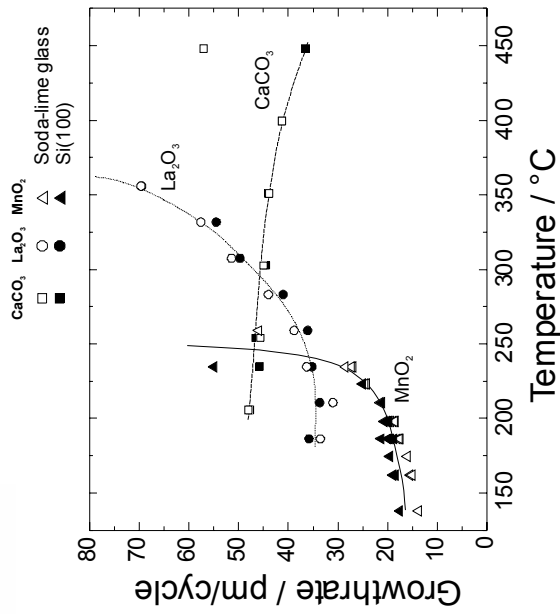
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# ALD-window

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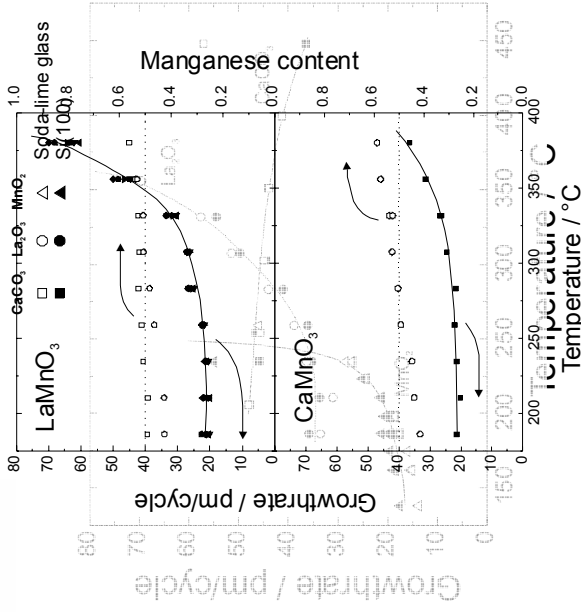
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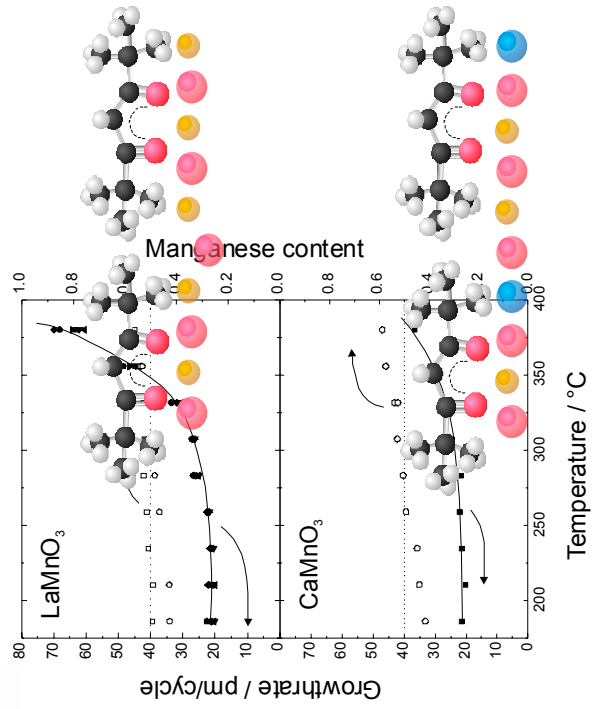
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# ALD-window

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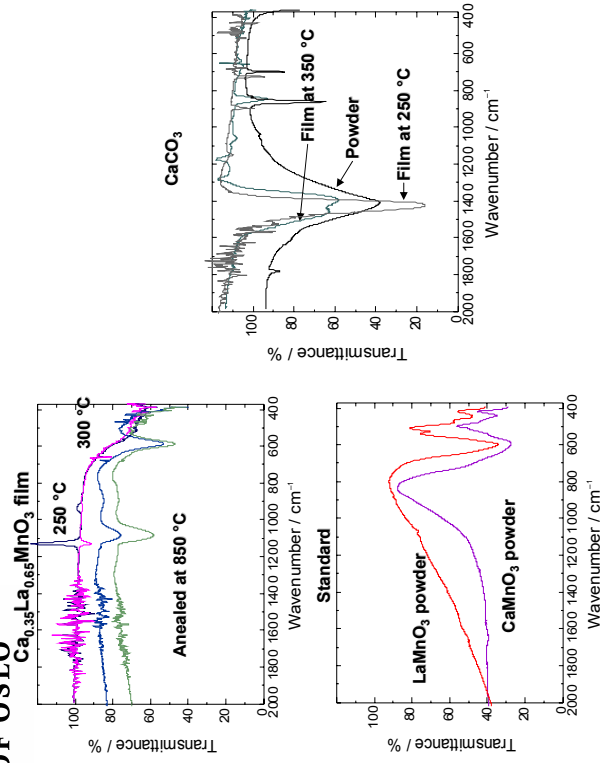
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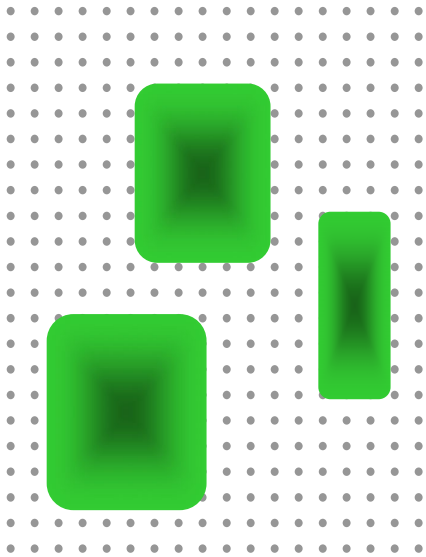
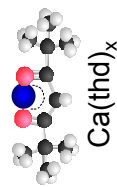
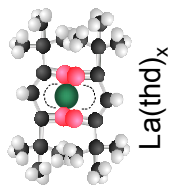
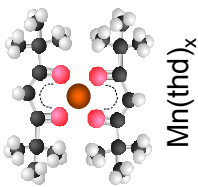
# Carbonate formation?

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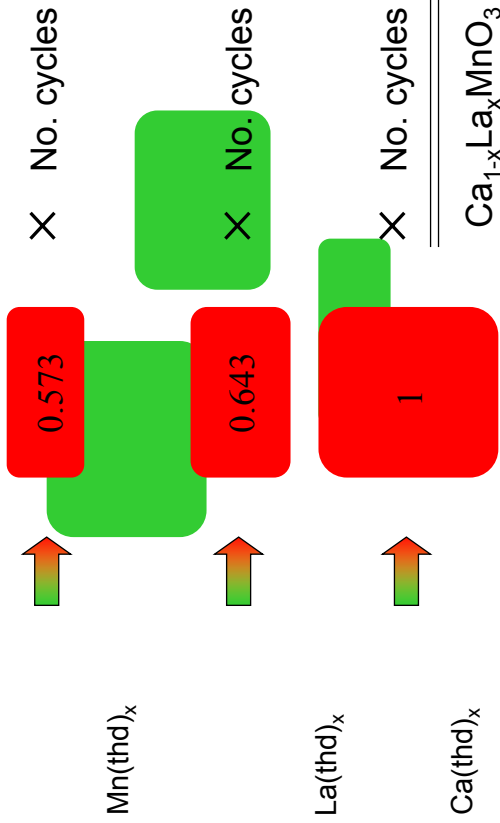
# Surface utilisation



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# Surface utilisation

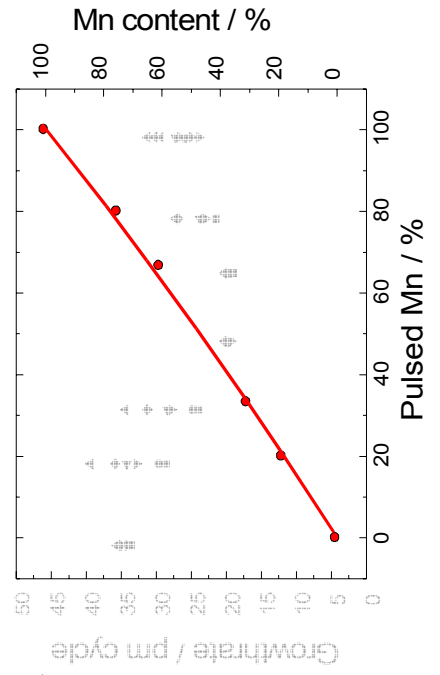
Growthrate Composition



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# Composition

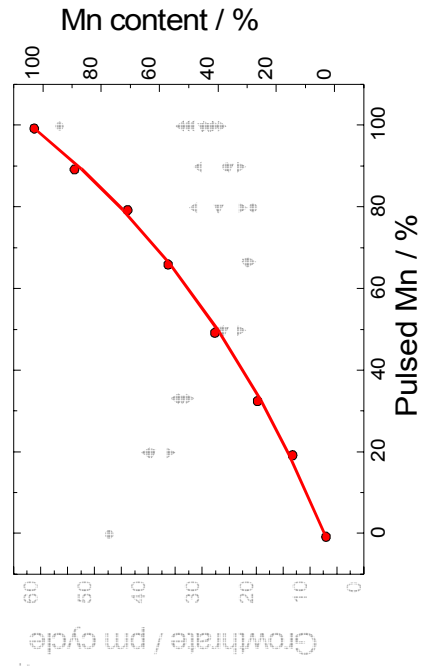
La : Mn



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# Composition

Ca : Mn



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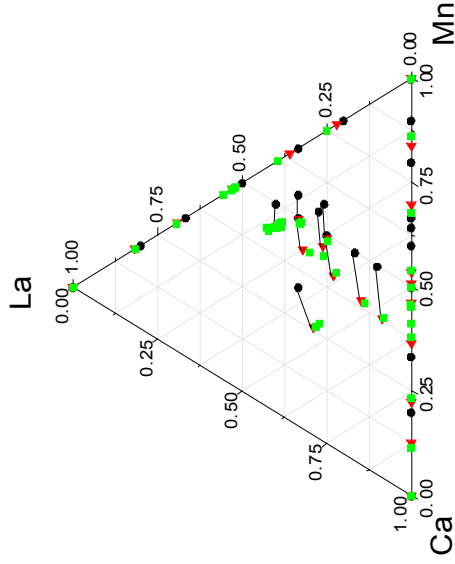
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# Composition

Tr = 250 °C

Ca: 1  
La: 0.643  
Mn: 0.573

● Pulsed  
▼ Calculated  
■ Measured

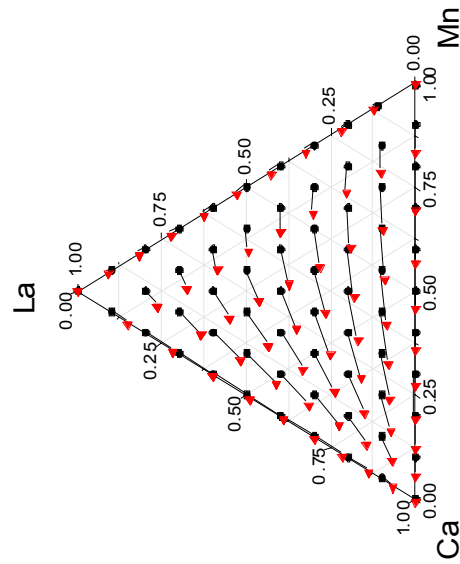


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Tr = 250 °C

Ca: 1  
La: 0.643  
Mn: 0.573

● Pulsed  
▼ Calculated



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# Composition

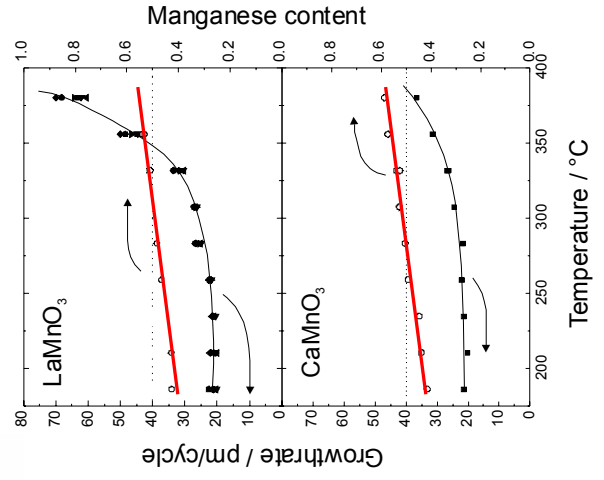


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# Composition - Temperature

Tr = 250 °C

● Pulsed  
▼ Calculated  
■ Measured



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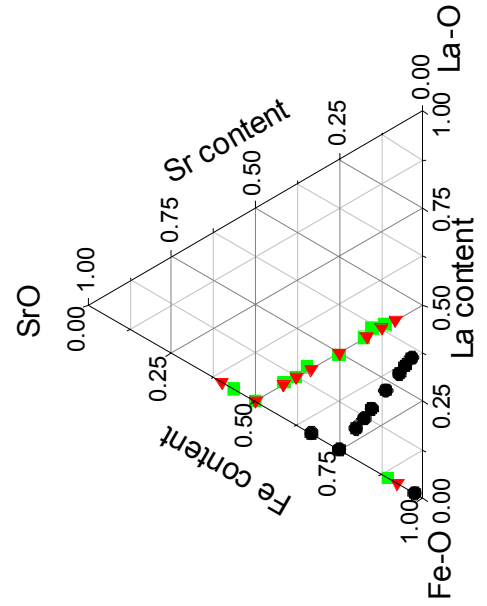


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# La-Sr-Fe-O

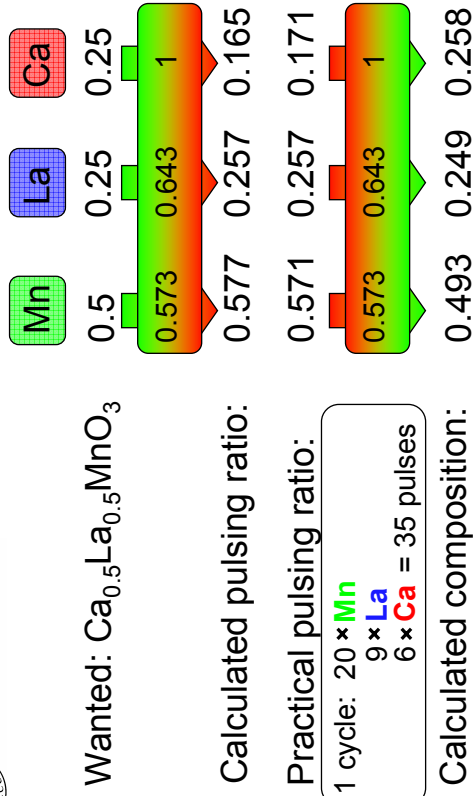
Tr = 250 °C

● Pulsed  
▼ Calculated  
■ Measured



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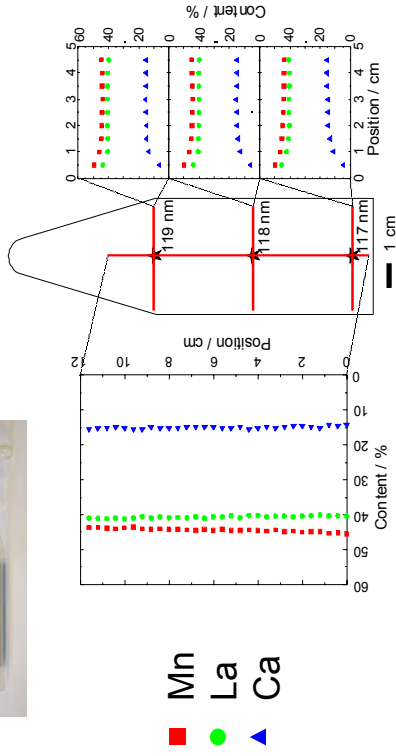
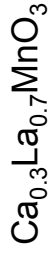
## Composition – The runs



Tr = 250 °C

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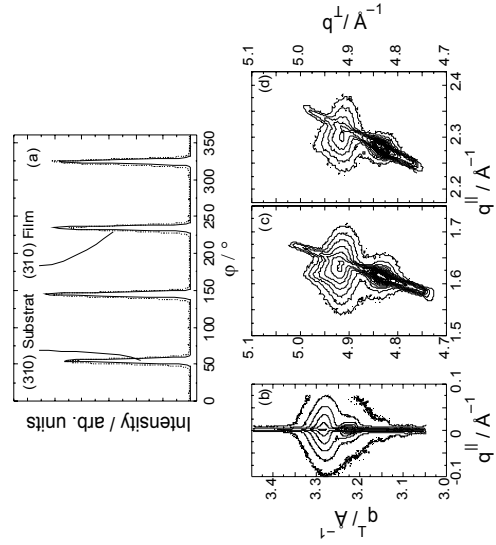
## Composition – Areal variations



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## $\text{Ca}_{0.35}\text{La}_{0.65}\text{MnO}_3$ on $\text{SrTiO}_3(100)$

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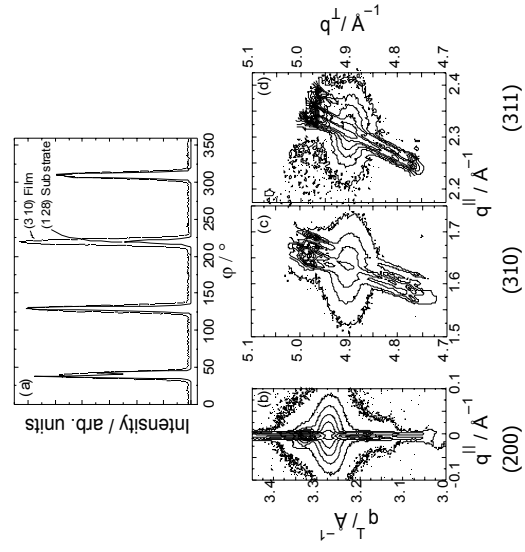


(200) (310) (311)

Tr = 300 °C

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(200) (310) (311)

Tr = 300 °C

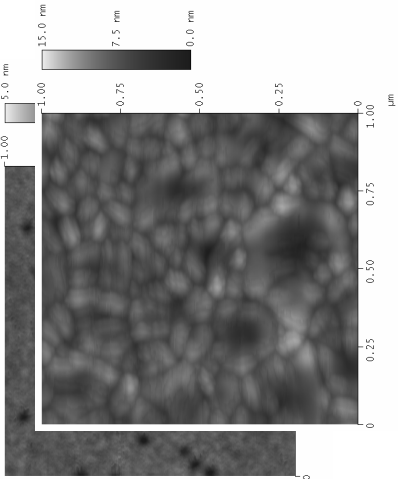
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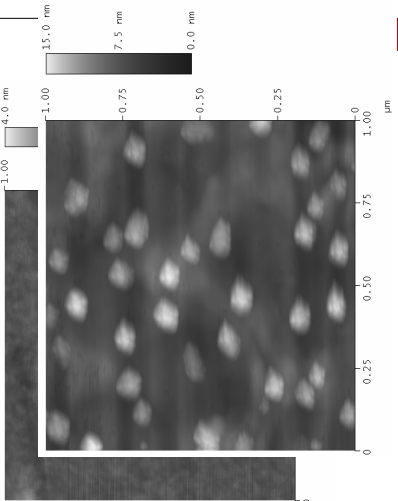
$\text{Ca}_{0.35}\text{La}_{0.65}\text{MnO}_3$  on  $\text{SrTiO}_3(100)$

Tr = 250 °C



Rms = 0.32 nm  
Rms = 1.5 nm

Tr = 300 °C



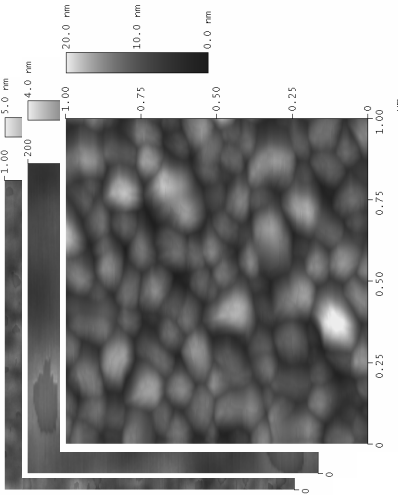
Rms = 0.16 nm  
Rms = 1.9 nm



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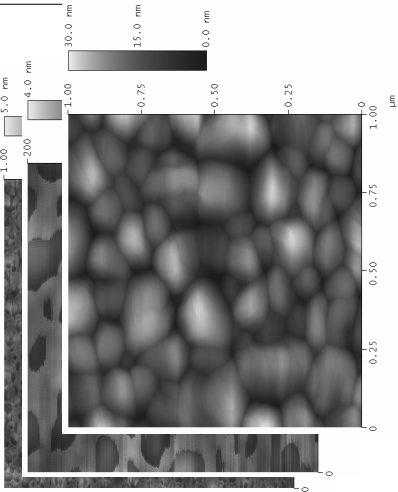
$\text{Ca}_{0.35}\text{La}_{0.65}\text{MnO}_3$  on  $\text{MgO}(100)$

Tr = 250 °C



Rms = 0.37 nm  
Rms = 3.0 nm

Tr = 300 °C

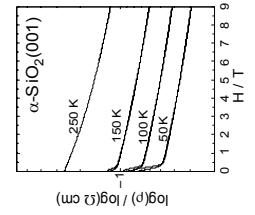
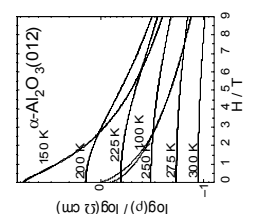
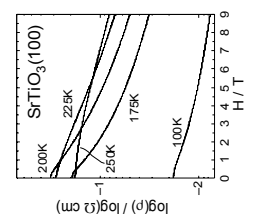
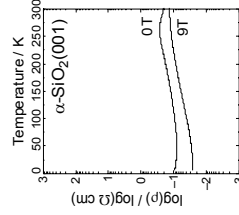
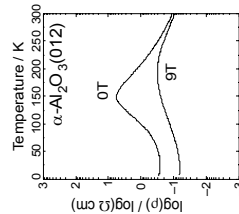
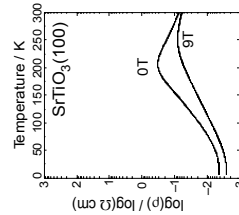


Rms = 0.53 nm  
Rms = 5.2 nm



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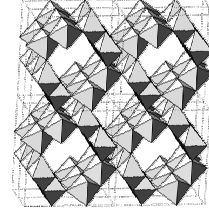
Effects of substrate



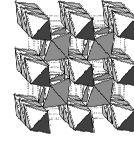
Grown film on substrates of:

- Soda-lime glass
- Si(100)
- Kapton™ foil
- $\alpha\text{-SiO}_2(001)$
- $\alpha\text{-Al}_2\text{O}_3(012)$
- $\alpha\text{-Al}_2\text{O}_3(001)$
- Muscovite(001)
- MgO(100)
- NaCl(100)
- KCl(100)
- KBr(100)
- KI(100)

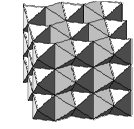
Obtained phases of:



$\alpha\text{-MnO}_2$



$\beta\text{-MnO}_2$



$\epsilon\text{-MnO}_2$

$\beta'\text{-MnO}_2$

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## Effects of substrate

### Grown film on substrates of:

Soda-lime glass

Si(100)

Kapton™ foil

$\alpha$ -SiO<sub>2</sub>(001)

$\alpha$ -Al<sub>2</sub>O<sub>3</sub>(012)

$\alpha$ -Al<sub>2</sub>O<sub>3</sub>(001)

Muscovite(001)

MgO(100)

NaCl(100)

KCl(100)

KBr(100)

KI(100)

$\beta'$ -MnO<sub>2</sub>(100)

$\beta'$ -MnO<sub>2</sub>(100)

### Obtained phases of:

$\beta$ -MnO<sub>2</sub>(100)

$\beta$ -MnO<sub>2</sub>(104)

$\epsilon$ -MnO<sub>2</sub>(001)

$\beta$ -MnO<sub>2</sub>(100)

$\beta$ -MnO<sub>2</sub>(110)

$\alpha$ -MnO<sub>2</sub> +  $\beta$ -MnO<sub>2</sub>

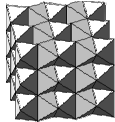
$\alpha$ -MnO<sub>2</sub>(100) +  $\beta$ -MnO<sub>2</sub>(100)

$\alpha$ -MnO<sub>2</sub>(110) +  $\beta$ -MnO<sub>2</sub>(100)

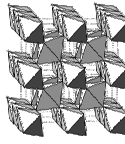
$\alpha$ -Mn<sub>2</sub>O<sub>7</sub>

$\beta$ -MnO<sub>2</sub>

$\beta$ -MnO<sub>2</sub>

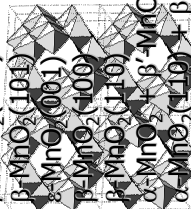


$\epsilon$ -MnO<sub>2</sub>



$\beta$ -MnO<sub>2</sub>

$\beta$ -MnO<sub>2</sub>



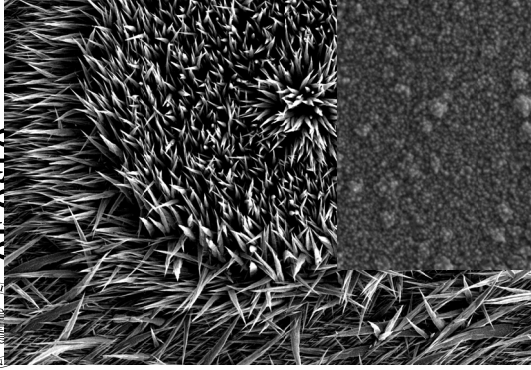
$\alpha$ -MnO<sub>2</sub>

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## MnO<sub>2</sub> on Al<sub>2</sub>O<sub>3</sub>



Det. Mag Pr  
ETD.3918x

Det. Mag Pressure WD 8/23/2004  
ETD.20000x 9.2 mm 1:45:52 PM

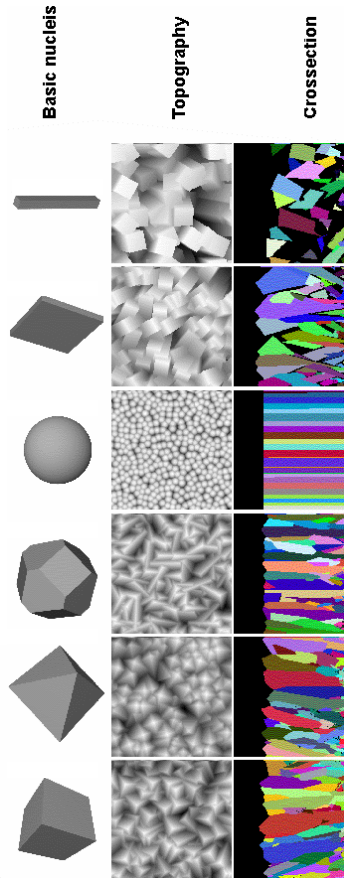
5.0µm  
MnO2 on AlO0.1 ca. 800 nm

5.0µm  
MnO2 on AlO0.1 ca. 800 nm



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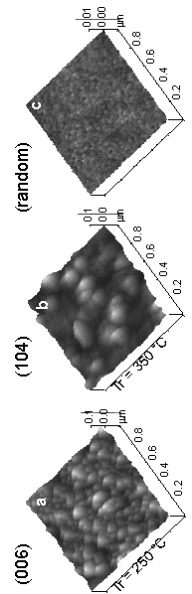
## Growthdynamics



Basic nuclei

Topography

Crosssection



(006)

(104)

(random)

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